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#### Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

### Listing of Claims:

(currently amended) A display device including a <u>main</u> semiconductor layer formed on a substrate and a plurality of thin film transistors having the semiconductor layers, wherein:

the <u>main</u> semiconductor layer includes a first pseudo single crystal region and a second pseudo single crystal region which is formed at a position separated from the first pseudo single crystal region, and

eut-of the plurality of thin film transistors, two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are arranged in the same pseudo single crystal region.

2. (currently amended) A display device including <u>a\_semiconductor layers</u>

<u>layer formed on a substrate and having pseudo single crystal regions, and a plurality of thin film transistors arranged in the inside of the pseudo single crystal regions, wherein:</u>

in the pseudo single crystal region, the semiconductor <u>layer</u> includes crystals which are grown in an elongate strip-like shape in <u>the a</u> direction parallel to the substrate, and

eut-of the plurality of thin film transistors, two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, have the direction of a the length of gates of the respective thin film transistors arranged with an inclination of within ±20 degree with

respect to the longitudinal direction of the strip-like grown crystals, and are arranged such that, when channel regions of the respective thin film transistors are imaginarily extended in parallel to the growth direction of the strip-like grown crystals, at least portions of the channel regions are superpose-superposed on each other.

- 3. (currently amended) A display device according to claim 2, wherein a rate extent of the superposition of the channel regions is 50% or more.
- 4. (currently amended) A display device according to claim 3, wherein a rate extent of the superposition of the channel regions is 80% or more.
- 5. (currently amended) A display device including <u>a</u> semiconductor <del>layers</del> layer formed on a substrate and having pseudo single crystal regions, and a plurality of thin film transistors arranged in the inside of the pseudo single crystal regions, wherein:

in the pseudo single crystal region, the semiconductor <u>layer</u> includes crystals which are grown in an elongate strip-like shape in <u>the a</u> direction parallel to the substrate, and

eut-of the plurality of thin film transistors, two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, have the direction of athe length of gates of the respective thin film transistors arranged with an inclination of within ±20 degree with respect to the longitudinal direction of the strip-like grown crystals, and are arranged such that the directions of currents which flow in the respective thin film transistors are aligned with each other.

6. (currently amended) A display device according to claim 1, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to

each other as the characteristics of the transistors, are formed of a differential pair of transistors which constitute a differential amplifying circuit.

- 7. (currently amended) A display device according to claim 1, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit.
- 8. (currently amended) A display device according to claim 1, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit and a transistor having a gate thereof to which an output voltage of the active load circuit is applied.
- 9. (currently amended) A display device according to claim 1, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are formed of a pair of transistors which constitute a current mirror circuit.
- 10. (currently amended) A display device according to claim 1, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are connected in parallel to each other, thus equivalently constituting one transistor.
- 11. (currently amended) A display device according to claim 2, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are formed of a differential pair of transistors which constitute a differential amplifying circuit.

- 12. (currently amended) A display device according to claim 2, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit.
- 13. (currently amended) A display device according to claim 2, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit and a transistor having a gate thereof to which an output voltage of the active load circuit is applied.
- 14. (currently amended) A display device according to claim 2, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are formed of a pair of transistors which constitute a current mirror circuit.
- 15. (currently amended) A display device according to claim 2, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are connected in parallel to each other thus equivalently constituting one transistor.
- 16. (currently amended) A display device according to claim 5, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are formed of a differential pair of transistors which constitute a differential amplifying circuit.
- 17. (currently amended) A display device according to claim 5, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to

each other as the characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit.

- 18. (currently amended) A display device according to claim 5, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are formed of a pair of transistors of an active load circuit which constitutes a differential amplifying circuit and a transistor having a gate thereof to which an output voltage of the active load circuit is applied.
- 19. (currently amended) A display device according to claim 5, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the characteristics of the transistors, are formed of a pair of transistors which constitute a current mirror circuit.
- 20. (currently amended) A display device according to claim 5, wherein two or more thin film transistors, which are required to exhibit small irregularities relative to each other as the-characteristics of the transistors, are connected in parallel to each other thus equivalently constituting one transistor.